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Defect-limited thermal conductivity in MoS2

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Abstract

The wide measured range of thermal conductivities (k) for monolayer MoS₂ and corresponding incongruent calculated values in the literature all suggest that extrinsic defect thermal resistance is significant and varied in synthesized samples of this material. Here we present defect-mediated thermal transport calculations of MoS₂ using interatomic forces derived from density functional theory combined with Green's function methods to describe phonon-point-defect interactions and a Peierls-Boltzmann formalism for transport. Conductivity calculations for bulk and monolayer MoS₂ using different density functional formalisms are compared. Non-perturbative first principles methods are used to describe defect-meditated spectral functions, scattering rates, and phonon k, particularly from Sulfur vacancies (V_S), and in the context of the plethora of measured and calculated literature values. We find that k of monolayer MoS₂ is sensitive to phonon-V_S scattering in the range of experimentally observed densities, and that first principles k calculations using these densities can explain the range of

measured values found in the literature. Furthermore, measured k values for bulk MoS₂ are more consistent because V_S defects are not as prevalent.

I. INTRODUCTION

Transition metal dichalcogenides, MoS_2 in particular, have enjoyed strong attention in basic and applications-based research, partly because monolayers can be easily cleaved from the corresponding bulk materials, like graphene, and partly because they are tuneable bandgap semiconductors (depending on layer thickness), unlike graphene. Vibrational properties and lattice thermal transport can play critical roles in determining limitations and functionalities of potential applications. For example, as electronic devices shrink toward the nanoscale, power densities vastly increase and thermal management is a key factor for improved device performance.

An abundance of experimental [1-19] and theoretical [20-38] investigations have examined thermal transport and its underlying vibrational properties in bulk, multilayer, and monolayer MoS_2 only to raise a variety of questions, including: What is the role of defects and size in limiting thermal conductivity (*k*)? How do different synthesis and characterization techniques lead to quantitatively different *k* values in these systems? What interatomic descriptions best describe the phonon interactions that govern *k* behavior? To illustrate these questions, **Figure 1** compiles a variety of calculated and measured room temperature (RT) *k* values from the literature and compares with our calculations for bulk and monolayer RT in-plane *k* as a function of sample size (calculation details are given in **Section II**). As long mean free path phonons carry a significant portion of heat in monolayer and van der Waals (vdW) layered materials *k* values can be sensitive to size effects even at RT. Measured in-plane multilayer and bulk MoS_2 RT *k* values range from 30-35 W/m-K (thin films) [15, 19] to 110 W/m-K [5], while calculations range from ~80 W/m-K [31] to 390 W/m-K [34] (some anomalously low values from molecular dynamics simulations are neglected here). For monolayer MoS_2 the experimental range of RT in-plane *k* values is 13 W/m-K [13] to 84 W/m-K [7], while the theoretical range for these is 20 W/m-K [27] to 400 W/m-K [24]. Generally, there is a large spread of calculated and measured *k* values for bulk and monolayer MoS_2 , and discrepancies among them that are not fully understood.

As measured and calculated k values vary significantly due to size effects (sample size and characterization techniques) and defects (including point defects, isotopes, and polymer residues), this article gives a synopsis of literature values in the context of our calculated values for both monolayer and bulk MoS₂. We give a description of vibrational and transport properties in these systems from density functional theory (DFT) calculations, comparing values obtained from the local density approximation (LDA) and the generalized gradient approximation (GGA). More importantly, we describe phonon-defect-limited k in monolayer MoS₂ fully from first principles Green's function methods to understand discrepancies between measured and calculated k values. Dilute Sulfur vacancies (V_S) provide significant thermal resistance for heat-carrying phonons, and calculations here are compared with previous work considering much larger defect densities [28].

In Section II, intrinsic vibrational properties and transport behaviors of MoS_2 systems are discussed in the context of DFT-derived Peierls-Boltzmann transport [39-41]. Section III gives a description of the DFT-derived Green's function method [42-44] used for describing defect-limited thermal transport. Section IV summarizes this work.

II. INTRINSIC PHONONS AND CONDUCTIVITY

DFT-derived Peierls-Boltzmann transport has been discussed in great detail in a variety of previous works [45-49]. Details specific to the MoS₂ calculations are provided here.

Calculation details – Calculations of structural parameters [in-plane lattice constant (*a*), cross-plane lattice constant (*c*) [bulk only], and distance between consecutive S layers (d_{S-S})] and interatomic force constants [harmonic (phonons) and anharmonic (three-phonon interactions)] were derived from DFT using the Quantum Espresso (QE) package [50]. Electronic structure calculations for monolayer MoS₂ used 13x13x1 k-integration meshes, an 80 Ry plane wave energy cutoff, Martins-Troullier (MT) pseudopotentials [51] to represent the core electrons, and a vacuum space between layers ~15 Å resulting in: *a*=3.190 Å and *d*_{S-S}=3.147 Å for GGA (Perdew-Burke-Ernzerhof exchange and correlations [52]) and *a*=3.091 Å and *d*_{S-S}=3.097 Å for LDA (Perdew-Wang (PW) exchange and correlations [53]). As reported in the supplemental material of our previous work [19], a 6x6x6 k-integration mesh, 70 Ry plane wave energy cutoff, MT pseudopotentials, LDA-PW exchange and correlations for bulk MoS₂ (no vacuum space needed) give: *a*=3.094 Å, *c*=12.069 Å, and *d*_{S-S}=3.099 Å.

Harmonic and anharmonic IFCs of MoS₂ were determined by numerical differentiation built from forces calculated on sets of 9x9x1 supercells (243 atoms) with appropriate atoms perturbed by 0.03 Å from their equilibrium positions. A cutoff of ~9.75 Å (~5.60 Å) was used to truncate the harmonic (anharmonic) IFCs. Translational invariance of the anharmonic IFCs was enforced by slightly altering the irreducible IFC set (those not related by symmetries of the crystal structure and derivative permutation) using a χ^2 minimization procedure described in previous work [54, 55]. A similar procedure was employed for the manipulation of the harmonic IFCs, however, additionally including rotational invariance [56, 57] and Born-Huang equilibrium constraints [57, 58]. These ensure that the low-frequency behavior of the flexure acoustic (ZA) branch is quadratic [58, 59]. The inset in **Figure 2** shows calculations of the ZA branch of monolayer MoS₂ using uncorrected harmonic IFCs [negative frequency values (imaginary phonons)] compared with these using symmetry-corrected IFCs (quadratic curve). Further details regarding IFC calculations for bulk MoS_2 are given in Ref. [19]. QE input files, harmonic IFCs, and anharmonic IFCs are given in the supplemental information [60]; other information can be provided upon request.

Phonons and k – The LDA calculated in-plane lattice parameter for monolayer MoS₂ is ~3% smaller than the GGA calculated values. This discrepancy is typical [61] and translates into harder phonons predicted by the LDA. **Figure 2** gives the phonon dispersions for monolayer MoS₂, both LDA and GGA, along high symmetry directions and compared with available measured data and the LDA calculated dispersion for bulk MoS₂. For the lowest acoustic frequencies the variations in the dispersions predicted by the LDA and GGA are small; however, for the optic branches and higher acoustic frequencies variations are apparent. Harder acoustic phonons have generally larger velocities (\vec{v}_{qj}) for these heat-carrying modes and higher optic phonon branches tend to reduce acoustic-optic phonon couplings giving larger transport lifetimes (τ_{qja}). Here, \vec{q} is the wave vector, *j* is the polarization, and α is the Cartesian direction for a particular phonon mode.

Since the thermal conductivity is given by:

$$k_{\alpha} = \sum_{\bar{q}j} C_{\bar{q}j} v_{\bar{q}j\alpha}^2 \tau_{\bar{q}j\alpha}$$
(1)

larger velocities and lifetimes give larger k. Equation 1 is a sum over all phonon modes in the first Brillouin zone and $C_{\bar{q}j} = (\hbar \omega_{\bar{q}j})^2 n_{\bar{q}j}^0 (n_{\bar{q}j}^0 + 1) / k_B T^2$ is the mode heat capacity with $n_{\bar{q}j}^0$ the Bose-Einstein distribution and $\omega_{\bar{q}j}$ the phonon frequency. Generally, k is a tensor; however, for monolayer MoS₂ k is described by a single parameter for in-plane transport and the layer thickness is defined as 6.033 Å, the distance between bulk MoS₂ layers [22]. For bulk MoS₂, k is

described by separate in-plane and cross-plane components. Cross-plane *k* is not considered in this work. All *k* calculations here include three-phonon interactions and phonon-isotope scattering from naturally-occurring isotope concentrations (14.65% ⁹²Mo, 9.19% ⁹⁴Mo, 15.87% ⁹⁵Mo, 16.67% ⁹⁶Mo, 9.58% ⁹⁷Mo, 24.29% ⁹⁸Mo, and 9.75% ¹⁰⁰Mo, 94.99% ³²S, 0.75% ³³S, 4.25% ³⁴S, 0.01% ³⁶S) derived from quantum perturbation theory [63-65]. Size dependence was determined by including phonon-boundary scattering rates of the empirical form $1/\tau_{\bar{q}\bar{q}}^{b} = 2|v_{\bar{q}\bar{q}}|/L$ where α is taken along the transport direction. Details of phonon-V_S scattering are given in the next section. From these scattering rates the transport lifetimes are calculated by self-consistently solving the Peierls-Boltzmann transport equation to determine the nonequilibrium phonon distributions [66-68]. Here, the extrinsic defect scattering rates are treated within the relaxation time approximation (RTA) [40, 41, 67].

As demonstrated in **Figure 1**, LDA *k* values calculated here for monolayer MoS₂ are higher than those from the GGA (178 and 143 W/m-K at RT, respectively). In general, this is also true of the calculated literature values in **Figure 1**, though with significant spread. We note that there are many more GGA *k* calculations than LDA reported in the literature for monolayer MoS₂. For bulk k_{in} , the opposite is true, more LDA calculations exist, and both LDA and GGA give more consistent results. To verify the robustness of our calculations, independent GGA monolayer *k* calculations were performed using combined VASP [69], Phonopy [70], and Phono3py simulation packages [71]. Here, an 18 Å vacuum and 520 eV (~38 Ry) energy cutoff give a=3.176 Å. Harmonic IFCs were calculated from 9x9x1 supercells using Γ -point only calculations. Anharmonic IFCs were similarly calculated though with 7x7x1 supercells and truncated interactions at 6.75 Å. For the *k* calculations a 55x55x1 integration grid was used with delta functions in phonon-phonon matrix elements approximated by an adaptive Gaussian function with a smearing parameter of 1.0 [71]. From this method the calculated monolayer k is 127 W/m-K, ~10% lower than our other GGA calculation.

Measured k_{in} values for bulk MoS₂ span a large range of values; however, considering the largest values over the range of system sizes available, theory gives a good description of the experiments. This suggests that for the lower measured values other extrinsic effects may be providing significant thermal resistance, e.g., point defects or uncharacterized grain boundaries. All measured *k* values for monolayer MoS₂ lie well below our calculations (both LDA and GGA), most other calculations, and below the highest bulk measurements. This is surprising as interlayer interactions are expected to reduce in-plane *k* for bulk as compared with monolayer systems, as found in calculations. The cause for these discrepancies may derive from phonon scattering from defects and surface residues for which monolayer systems may be more sensitive. Defect-limited *k* of monolayer MoS₂ is examined in the next section.

III. EXTRINSIC PHONON-DEFECT INTERACTIONS

Defects in bulk and monolayer MoS₂ have been intensively explored [72-75], particularly related to their effects on thermal transport [11, 18, 19], electronic transport [76], and photoluminescence excitations [77, 78]. Among the variety of possible point defects (e.g., vacancy complexes, adatoms, vacancies, antisite defects) the most prevalent in monolayer MoS₂ synthesized by chemical vapor deposition or mechanical exfoliation are single Sulfur vacancies (V_s) [72, 73] with average concentrations estimated ~1.2x10¹³ cm⁻² (a bit shy of 1%) and ranging from 0.5 to 3.5 x10¹³ cm⁻² [72]. Previous first principles calculations have demonstrated that vacancies, even at low concentrations, can provide significant thermal resistance in a variety of materials as they strongly perturb the crystal via mass variation, restructuring around the vacancy center, and resulting force constant variations [79-82]. In fact, recent first principles calculations

have demonstrated a large reduction in k of monolayer MoS₂ [28], though for periodic defect distributions and concentrations significantly higher than found in experiments, as they were limited by supercell size. Thus, here we study defect-limited k of MoS₂ with Sulfur vacancies and Sulfur adatoms in the dilute limit using Green's function techniques.

To describe phonon-defect scattering we use a non-perturbative T-matrix methodology with harmonic IFCs from DFT supercells of perfect monolayer MoS₂ and from those with a single defect as inputs. This technique has been described in previous work [43, 79-83]; only details relevant to monolayer MoS₂ are presented here. IFC calculations for phonon-defect interactions are similar to those described above for the harmonic IFCs, though using 7x7x1 supercells (147 atoms) with atomic perturbations of 0.04 Å and including interactions to nineteenth nearest neighbors (up to 9.87 Å in the perfect system). We only considered neutral defects here and note that a spectroscopic study as well as theoretical calculations found that V_S defects can switch between neutral and -1 charge states [84, 85]. Forces were relaxed within 0.0005 Ry Bohr⁻¹ for the single defect supercell in a series of calculations. First, the defect and nearest neighbor atoms were allowed to freely relax to new equilibrium positions while keeping all other atoms fixed. The next relaxation calculation allowed the defect, nearest neighbors, and second nearest neighbors to find relaxed positions. Progressively more neighboring shells were included in a series of calculations until all atoms in the supercell obtained new relaxed equilibrium positions. After relaxation, atoms around the Vs contract. In particular, the first neighbor distance shrinks from 2.422 Å to 2.387 Å for the S atom on the opposite side of the monolayer with respect to the vacancy. On the other hand, atoms around the S adatom slightly expand. The distance from the S atom just below the S adatom to its first nearest neighbors increases from 2.422 Å to 2.427 Å. Moreover, the distance between the adatom and its nearest neighbor is 1.939 Å. The relaxed

atomic equilibrium positions for the defect supercells are given in QE input files in the supplemental information [60]. The differences in harmonic IFCs from the perfect and defect supercells build into the T-matrix and resulting phonon-defect scattering rates [43, 79-83]. These scattering rates are included in the Peierls-Boltzmann transport equation within the RTA, similar to phonon-isotope and phonon-boundary scattering.

Before examining defect-limited k, Figure 3 demonstrates the mode broadening induced by phonon-V_S interactions in monolayer MoS₂, though beyond the dilute limit here with V_S density 22.7×10^{13} cm⁻² (10% of Sulfur atoms) for better visualization of the influence of disorder on the calculated phonon structure. This spectral function is configurationally averaged using an effective disordered Hamiltonian method [86, 87]. Similar to the Green's function method described above, an impurity potential is defined by the difference of harmonic IFCs with and without a single V_S. From this, twenty different effective Hamiltonians are constructed for supercells with an average of 560 atoms and 40 randomly located V_S defects (and varying supercell shapes), each with density $\sim 22.7 \times 10^{13}$ cm⁻², by removing the force constants corresponding to the missing Sulfur atoms and adjusting the remaining IFCs according to the calculated V_S impurity potential. Following the unfolding formula of Ref. 88 atomically resolved spectral functions for each randomly configured supercell are computed by exact diagonalization of the constructed Hamiltonians. These are averaged to give the spectral dispersion of Figure 3. For each disordered supercell construction, IFCs were altered to ensure that restoring forces on each atom were equal and opposite to the induced forces on the other atoms (Newton's third law); otherwise, spurious imaginary frequencies are present. Not surprisingly, the disorder broadens the phonon bands in momentum space and frequency space, corresponding to finite mean free paths and lifetimes induced by scattering of the phonons by V_S disorder. Significant broadening occurs for acoustic modes in the ~5 and ~6 THz regions (see **Figure 3**) where the bands are flattened and more susceptible to disorder-induced phonon scattering. This is qualitatively consistent with the results obtained from the T-matrix method (scattering rates in **Figure 5**).

Including phonon-V_s interactions (from the Green's function description) with defect densities estimated from experiment severely reduces the calculated k of monolayer MoS₂. The inset to **Figure 4** gives the GGA calculated RT k of monolayer MoS₂ as a function of V_s density and scaled by k with no phonon-V_s scattering. Also shown are calculated RT k as a function of Sulfur adatom density. We find that adatoms provide significantly stronger thermal resistance, particularly for lower frequency phonons (see **Figure 5**); however, the literature does not suggest that these defects have comparable densities to those found for V_s defects. The green box denotes the range of V_s densities observed in measurements, while the green circle gives the average V_s concentration [72]. The range of observed V_s densities corresponds to the largest variance in k via phonon-V_s scattering, from 20% to 70% of its intrinsic value. This defect

sensitivity may be the primary reason for the diversity of measured monolayer $MoS_2 k$ values in the literature.

Also shown in Figure 4 are two calculated monolayer $MoS_2 k$ values including Sulfur vacancies with large defect densities from Ref. 28. It is not clear why these calculated k values are much larger than those predicted here; however, we highlight three important calculation differences. First, the defect densities are large enough for defect correlations [89] to become non-negligible. We consider randomly distributed isolated defects, while Ref. 28 considers periodically ordered V_s. Second, the $3x_3x_1$ supercells (27 atoms) that made the calculations in Ref. 28 tractable are quite small. This may lead to spurious supercell interactions that can stiffen the vibrational frequencies and give higher k. Third, the defect supercells in Ref. 28 were not relaxed after incorporating each V_s in the perfect system. Local distortions around vacancies after relaxation were shown to provide important thermal resistance in diamond [79] and graphene [81]. In graphene, these distortions gave enhanced phonon-defect scattering particularly at higher vacancy concentrations (see Figure 13(c) of Ref. [81]).

Figure 6 gives the GGA calculated *k* of monolayer MoS₂ including phonon-V_S scattering as a function of system size. The dark gray curve corresponds to the average V_S concentration, while the gray area gives the calculated *k* for the concentration range of 0.5 (top of area) to 3.5 (bottom of area) $x10^{13}$ cm⁻². Using the same phonon-V_S scattering rates (determined from GGA supercells) with the LDA *k* calculation shifts this gray area upward the same difference found between the LDA and GGA *k* calculations in **Figure 1** (~15%). Indeed, the defect-mediated *k* calculations cover the observed range of measured monolayer MoS₂ *k* values barring a single data point with a very low value [13]. This strongly suggests that these V_S vacancies play a critical role in thermal transport and are the primary driver for observed discrepancies among

experiments and when comparing with theoretical results. Furthermore, better general agreement between the highest measurements and calculations of *k* for bulk MoS₂ (see **Figure 1**) likely occurs because observed estimated V_S densities range from 0.007 to 0.03 $\times 10^{13}$ cm⁻² [74, 75] in bulk, orders of magnitude smaller than those in monolayer MoS₂.

The severe reduction of thermal conductivity via Sulfur vacancies follows from its relatively large scattering strength. **Figure 5** gives the calculated three-phonon (at RT), phonon-V_S (density 1.2×10^{13} cm⁻²), phonon-S-adatom (same defect density), phonon-isotope (natural S and Mo isotope abundances), and phonon-boundary (*L*=5µm) scattering rates for the six lowest frequency branches including the acoustic phonons. At higher frequencies phonon-isotope scattering is comparable to the anharmonic and phonon-V_S scattering rates, while at very low frequencies the boundary scattering becomes important. However, for this set of parameters, the anharmonic and phonon-V_S scatterings provide more significant thermal resistance, and their scattering rates have very similar magnitudes over the acoustic frequency range. Thus, the monolayer MoS₂ *k* is sensitive to the defect density in the experimentally observed density range. Sulfur adatoms are particularly effective at scattering low frequency acoustic phonons and thus may provide strong thermal resistance similar to phonon-V_S scattering even for lower defect concentrations.

For lower (higher) temperatures the anharmonic scattering rates decrease (increase), while the defect-mediated scattering rates are insensitive to temperature. Thus, at higher temperatures defects provide less relative resistance, while at low temperatures these mechanisms become dominant. For this reason, temperature-dependent k measurements can provide important information regarding thermal resistance mechanisms in particular MoS₂ samples. Figure 7 gives calculated k for bulk (LDA) and monolayer (GGA) MoS₂ as a function of temperature and

compared with available measured data for monolayer MoS₂. Surprisingly few measured temperature-dependent *k* values exist for monolayer MoS₂: a series of measurements on a supported sample [6] and two series with suspected surface residues and small grain sizes ~0.5 μ m [11]. Measured *k* values presented in **Figure 1** and **Figure 6** correspond to RT experiments. All measured curves demonstrate behavior inconsistent with the T⁻¹ *k* dependence of purely three-phonon scattering at higher temperatures. The supported sample gives ~T⁻⁵ temperature dependence, while the suspended samples are nearly temperature independent for T>150K. Further temperature-dependent *k* measurements on high quality monolayer MoS₂ samples are required to better understand its intrinsic *k* behavior and relation to extrinsic defects.

IV. SUMMARY

This work presented defect-limited thermal conductivity calculations of MoS_2 systems from DFT-derived Peierls-Boltzmann transport and Green's function methodologies in the context of the plethora of theoretical and measured values in the literature. Different density functional approximations were compared and the effects of Sulfur vacancies on vibrational spectral functions and size- and temperature-dependent *k* of monolayer MoS_2 were examined. In particular, we find that monolayer *k* values are sensitive to phonon-V_S scattering in the range of densities observed in experiments. This sensitivity can explain the wide range of measured monolayer MoS_2 *k* values in the literature and discrepancies found with theory. Furthermore, measurements and calculations of *k* for bulk MoS_2 are more consistent due to its having significantly less V_S densities.

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Figure Captions

Figure 1: Calculated (colors) and measured (black) room temperature k of monolayer and multilayer/bulk MoS₂ as a function of characteristic size. Curves represent calculated data generated here, while symbols are literature values [1-38] (numbers give references for some values, measured monolayer values can be found in **Figure 6**). The dashed curve and open symbols correspond to in-plane multilayer/bulk values, while the solid curves and filled symbols correspond to monolayer MoS₂ k. Note that the number of layers or layer thickness is not distinguished here. For the calculations, green corresponds to LDA values, red corresponds to GGA values, and purple corresponds to empirical potential descriptions of the interatomic interactions. 'Size' is estimated by the average lateral sample dimensions (length and width) or characterization method for measured k, e.g., diameter of laser spot size in thermo-reflectance measurements or hole in supporting substrate in Raman thermometry measurements. For calculated literature values a 'size' is given, while here size is determined by L described in the text. Calculations of k with no sample size (or 'infinite' size) are reported here at 100 µm.

Figure 2: Calculated phonon dispersions of monolayer (solid curves) and bulk (dashed curves) MoS_2 compared with measured data for monolayer (purple diamonds; Raman [18]) and bulk (black circles; neutrons [62]) MoS_2 . Green corresponds to LDA calculations, while red corresponds to GGA. **Inset:** Uncorrected low frequency dispersion of the flexure acoustic branch of monolayer MoS_2 using a 9x9 supercell (purple imaginary curve). The red curve corresponds to the symmetry-corrected dispersion, while the dashed green curve corresponds to the lowest frequency in-plane transverse acoustic branch of bulk MoS_2 .

Figure 3: Configurationally averaged disordered spectral dispersion of monolayer MoS_2 with V_S density 22.7x10¹³ cm⁻² (10% Sulfur atoms missing) with blue/red intensity corresponding to the Mo/S weight.

Figure 4: GGA calculated *k* of monolayer MoS₂ as a function of V_S (red curve) and S adatom (blue curve) density. The green box denotes the range of V_S densities found in Ref. 72 (0.5 to $3.5 \times 10^{13} \text{ cm}^{-2}$), while the green circle gives the estimated average V_S density of $1.2 \times 10^{13} \text{ cm}^{-2}$. The black diamonds are calculated values from Ref. 28 for V_S densities of 12.6 and 25.2 $\times 10^{13} \text{ cm}^{-2}$. The inset demonstrates the S adatom (blue) configuration above the top layer of Sulfur atoms (yellow).

Figure 5: GGA calculated phonon scattering rates for the six lowest frequency branches of monolayer MoS₂: three-phonon interactions at RT (black circles), phonon-V_S scattering with density of 1.2×10^{13} cm⁻² (red circles), phonon-S-adatom scattering with the same density, phonon-isotope scattering with natural Sulfur and Molybdenum concentrations (purple circles), and phonon-boundary scattering with *L*=5µm (green circles).

Figure 6: GGA calculated *k* of monolayer MoS₂ compared with RT measurements (numbers label references) as a function of size. The red curve and measured data (black squares) are the same as in Figure 1. The dark gray curve corresponds to the GGA calculated monolayer MoS₂ *k* including 1.2×10^{13} cm⁻² Sulfur vacancies (average estimated density in Ref. 72), while the gray area represents the range of *k* with V_S densities between 0.5×10^{13} cm⁻² and 3.5×10^{13} cm⁻² (range from Ref. 72). The inset shows a defect structure: Molybdenum atoms (purple), Sulfur atoms (yellow), and Sulfur vacancy (red).

Figure 7: Calculated k of bulk (dashed green curve) and monolayer (solid red and purple curves) MoS₂ as a function of temperature. Symbols represent measured MoS₂ k data:

black squares (bulk [12]), orange circles (supported monolayers [6]), and purple and blue circles (suspended monolayers [11]). The solid red and dashed green curves include anharmonic, phonon-isotope (natural isotope concentrations), and phonon-boundary (L=10µm) interactions. The solid purple curve includes anharmonic, phonon-isotope (natural isotope concentrations), phonon-boundary (L=0.5µm), and phonon-V_s (1.2x10¹³ cm⁻²) interactions.



Figure 1



scaled wave vector

Figure 2



Figure 3



Figure 4



Figure 5



Figure 6



Figure 7

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